

<b>Notice of References Cited</b>	Application/Control No. 10/593,809	Applicant(s)/Patent Under Reexamination NARAYAN ET AL.	
	Examiner JONATHAN C. LANGMAN	Art Unit 1784	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
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**FOREIGN PATENT DOCUMENTS**

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Stavrev et al. "Behavior of thin Ta-Based films in Cu/Barrier/Si system", J. Vac. Sci. Technol. A, Vol. 17, 1999, pgs 993-1001.
	V	
	W	
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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